

TSV (Through Hole Silicon Via) Materials Market and Supply Interposers

For Semiconductor Device Manufacturing

Techcet Group

a Techcet CA, LLC Company

Estimated Publication date:

January 2015

REPORT DESCRIPTION: Techcet's Critical Materials Report on TSV–Interposers provides detailed information on the markets dynamics, supply chain and technical trends associated with this growing market segment. Interposers materials can be a limiting factor in package size and end use application. The pros and cons of various interposer materials are reviewed in addition to the market drivers behind changing materials requirements. Market statistics, materials market forecasts as well as supplier market ranking and supplier profiles are also included.

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TSV-Interposers Page 1
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Table of Contents

PAGE #

1.0	Introduction - Why TSV?		
	 Reasons for TSV in today's semiconductor world 		
	■ 3D Evolution		
	 The Chip-Packaging GAP - the challenge to be solved 		
2.0	Overview of TSV/3D Technology		
	2.1	Process flow and Basic TSV technologies today	
	2.2	Include terminology – interposer, substrate, metallization	
	2.3	2D / 2.5D / 3D	
	2.4	materials used [metals; glass; laminates; dry film]	
3.0	Market Environment and Technology		
	3.1	TSV chip growth – make lots money - forecast	
	3.2	Where is the demand?	
	3.3	Challenges and opportunities	
	3.4	2D / 2.5D / 3D	
4.0	Materials for TSV / 3D applications		
	4.1	Interposer Materials – Glass, Silicon, Laminates	
	4.2	Main Focus for 3D Technology	
	4.3	Advantages for 3D	
	4.4	Characteristics of a good interposer/ substrate	
5.0	Materials Market Statistics		
	5.1	Supplier Base	
	5.2	Market Size / Growth	
	5.3	Market Share	
	5.4	Regional activity and position	
6.0	The S	The Supply Chain Dynamics	
7.0	Supplier Profiles and News		

TSV-Interposers Page 2
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